

1270.43264X00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: KOMATSU

Serial No.: New Application

Filed: November 6, 2003

For: PHOTORESISTIVE RESIN COMPOSITION, PROCESS FOR
FORMING RELIEF PATTERN, AND ELECTRONIC COMPONENT

Art Unit: Unassigned

Examiner: Unassigned

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

November 6, 2003

Sir:

Please amend the above-identified application, prior to calculation of the filing
fee, as listed in the following, and as set forth on the following pages:

Amendments to the Claims

Remarks are included following the amendments.